

A New Approach to the Synthesis of Unsymmetrical Disilenes and Germasilene: Unusual ^{29}Si NMR Chemical Shifts and Regiospecific Methanol Addition

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Summary: The reaction of dilithiosilanes (${}^t\text{Pr}_3\text{Si}$) $_2\text{SiLi}_2$ (**1a**) and (${}^t\text{Bu}_2\text{MeSi}$) $_2\text{SiLi}_2$ (**1b**) with diaryldichlorosilanes [Ar_2SiCl_2 , $\text{Ar} = \text{Mes}$ (2,4,6-trimethylphenyl) and *Tip* (2,4,6-triisopropylphenyl)] quantitatively produced the corresponding unsymmetrical 1,1-diaryl-2,2-bis(trialkylsilyl)disilenes, $\text{Ar}_2\text{Si}=\text{Si}(\text{SiR}_3)_2$ (**2**, $\text{R}_3\text{Si} = {}^i\text{Pr}_3\text{Si}$; **3**, $\text{R}_3\text{Si} = {}^t\text{Bu}_2\text{MeSi}$). A stable germasilene, $\text{Mes}_2\text{Ge}=\text{Si}(\text{SiMe}^t\text{Bu}_2)_2$ (**4**), was also synthesized by the reaction of **1b** with dimesityldichlorogermane. These compounds reveal unusual ^{29}Si NMR shifts and regioselective methanol additions.

Since tetramesityldisilene was first isolated as a stable Si=Si doubly bonded compound in 1981,¹ many other stable disilenes bearing various substituents such as alkyl-, aryl-, silyl-, and heteroatom-containing groups have been synthesized and characterized.^{2,3} Almost all stable disilenes have been synthesized by three methods: (A) photolysis of linear trisilanes such as $(\text{Me}_3\text{Si})_2\text{-SiAr}_2$ and consequent dimerization of the intermediate

silylene, Ar_2Si ; (B) photochemical cleavage of cyclo-trisilanes; and (C) reductive coupling of dihalosilanes. These general methods allow the preparation of disilenes of the type $\text{A}_2\text{Si}=\text{SiA}_2$ and $\text{ABSi}=\text{SiAB}$. Of course, disilenes having differently substituted silicon atoms, such as $\text{A}_2\text{Si}=\text{SiB}_2$, are also accessible by these methods; however, the resulting disilene $\text{A}_2\text{Si}=\text{SiB}_2$ is usually produced in a statistical mixture together with $\text{A}_2\text{Si}=\text{SiA}_2$ and $\text{B}_2\text{Si}=\text{SiB}_2$.^{3c,4} Methods for the selective synthesis of unsymmetrically substituted disilenes are currently very limited.⁵ For a germasilene, a regio-specific generation of ${}^t\text{Bu}_2\text{Si}=\text{GeMes}_2$ ($\text{Mes} = 2,4,6$ -trimethylphenyl) is reported by the photochemical reaction of Si,Si'-di-*tert*-butyltetramesitylsiladigermirane.⁶ Recently, we have reported the successful preparation and isolation of bis(triisopropylsilyl)dilithiosilane (**1a**) by the reaction of 3,3-bis(triisopropylsilyl)-1,2-bis(trimethylsilyl)-3-silacyclopentene with lithium metal in THF.⁷ We have also described some reactions of dilithiosilane with electrophiles such as chlorosilanes, and dilithiosilane was found to be a promising reagent for the synthesis of a variety of organosilicon compounds.^{7,8} We report here the reaction of dilithiosilane **1b** with dihalosilanes as electrophiles, which provides a new, highly effective route for the selective synthesis of unsymmetrical disilenes^{4,5} and germasilene.^{6,9} The un-

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(5) Unsymmetrical disilenes have been prepared by the reductive dehalogenation of the corresponding dihalodisilane derivatives. For $\text{Mes}_2\text{Si}=\text{SiTip}_2$, see: (a) Weidenbruch, M.; Pellmann, A.; Pan, Y.; Pohl, S.; Saak, W. *J. Organomet. Chem.* **1993**, *450*, 67. (b) For $({}^t\text{BuMe}_2\text{Si})_2\text{Si}=\text{Si}(\text{SiMe}^t\text{Pr})_2$, see ref 3k.

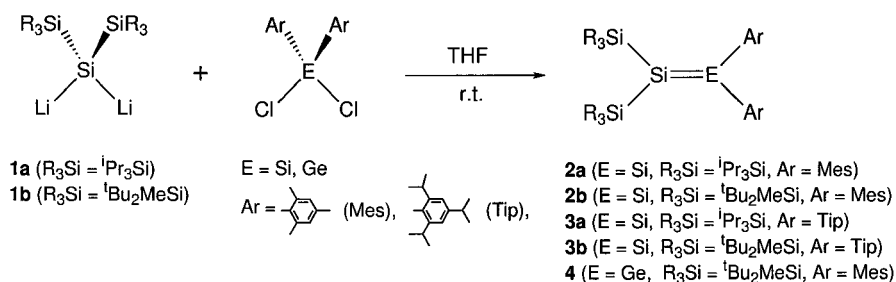
(6) Kolleger, G. M.; Stibbs, W. G.; Vittal, J. J.; Baines, K. M. *Main Group Met. Chem.* **1996**, *19*, 317.

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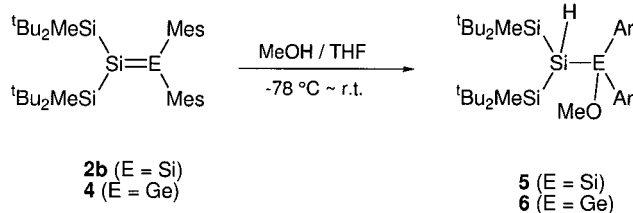
(8) (a) Tokitoh, N.; Hatano, K.; Sadahiro, T.; Okazaki, R. *Chem. Lett.* **1999**, 931. (b) Hatano, K.; Tokitoh, N.; Takagi, N.; Nagase, S. *J. Am. Chem. Soc.* **2000**, *122*, 4829.

(9) (a) Baines, K. M.; Cooke, J. A. *Organometallics* **1991**, *10*, 3419. (b) Baines, K. M.; Cooke, J. A. *Organometallics* **1992**, *11*, 3487. (c) Baines, K. M.; Cooke, J. A.; Dixon, C. E.; Liu, H. W.; Netherton, M. R. *Organometallics* **1994**, *13*, 631. Quite recently, we have reported the synthesis of 1,1,2,3-tetrakis[di-*tert*-butyl(methyl)silyl]-4-phenyl-1,2-disila-3-germacyclopenta-2,4-diene, which has a silole-type structure with Si=Ge and C=C double bonds; see: (d) Lee, V. Ya.; Ichinohe, M.; Sekiguchi, A. *J. Am. Chem. Soc.* **2000**, *122*, 12604. For 2-disilagermirene with a Si=Ge double bond, see ref 3q.

Scheme 1



Scheme 2



usual ^{29}Si NMR chemical shift of the sp^2 silicon atoms and the regioselective addition of methanol are also presented.

Dry oxygen-free THF was introduced by vacuum transfer to a mixture of bis[di-*tert*-butyl(methyl)silyl]dilithiosilane (**1b**)¹⁰ and dichlorodimesitylsilane, and the reaction mixture was stirred for 1.5 h at room temperature. The color of the reaction mixture immediately changed to red due to the formation of 1,1-dimesityl-2,2-bis[di-*tert*-butyl(methyl)silyl]disilene (**2b**), which was isolated quantitatively as a red-brown oil (Scheme 1).¹¹ In a similar manner, 1,1-diaryl-2,2-bis(trialkylsilyl)disilenes (**2a**, **3a**, and **3b**) were also prepared by the reaction of **1b** with the corresponding diaryldichlorosilanes in 92–96% yield. The germasilene **4** with a Si=Ge double bond was also synthesized by the reaction of the dilithiosilane **1b** with dimesityldichlorogermane in 94% yield.¹²

The structures of **2–4** were determined by mass, 1H , ^{13}C , and ^{29}Si NMR spectroscopies^{11–13} as well as by product analysis of the reaction with methanol (*vide infra*).

(10) Dilithiosilane **1b** was prepared from 3,3-bis[di-*tert*-butyl(methyl)silyl]-1,2-bis(trimethylsilyl)-3-silacyclopropene in a manner similar to that for **1a**. See ref 7.

(11) Procedure for synthesis of **2b**: Dry oxygen-free tetrahydrofuran (ca. 2 mL) was introduced by vacuum transfer to a mixture of 3,3-bis[di-*tert*-butyl(methyl)silyl]-1,2-bis(trimethylsilyl)-3-silacyclopropene (98 mg, 0.19 mmol) and lithium metal (ca. 10 mg, 1.4 mmol), and then the reaction mixture was stirred at room temperature for 1.5 h to give a red solution of bis[di-*tert*-butyl(methyl)silyl]dilithiosilane (**1b**). After the removal of solvent and bis(trimethylsilyl)acetylene in vacuo, **1b** was obtained as a pale yellow powder. In a glovebox, the lithium metal pieces were removed and then dichlorodimesitylsilane (62 mg, 0.19 mmol) was added. Dry oxygen-free tetrahydrofuran (ca. 2 mL) was introduced into the glass reaction vessel containing **1b** and dichlorodimesitylsilane, and then the reaction mixture was stirred at room temperature for 1 h to give a red-brown solution of **2b**. The solvent was removed in vacuo and then dry oxygen-free C_6D_6 (0.6 mL) was introduced into the reaction mixture. After filtration of the resulting lithium salt, the solvent was removed in vacuo to give pure **2b** as a red-brown oil (118 mg, 99%): 1H NMR (C_6D_6 , δ) 0.09 (s, 6 H), 1.18 (s, 36 H), 2.06 (s, 6 H), 2.80 (s, 12 H), 6.72 (s, 4 H); ^{13}C NMR (C_6D_6 , δ) -3.5, 21.1, 22.1, 26.0, 30.4, 128.7, 137.8, 139.4, 144.1; ^{29}Si NMR (C_6D_6 , δ) 8.2, 24.1, 148.6; HRMS m/z calcd for $C_{36}H_{64}Si_4$ 608.4085, found 608.4089; UV-vis (hexane) $\lambda_{max/nm}$ (ϵ) 289 (6700), 437 (3200).

(12) Spectroscopic data for **4**: 94% yield; 1H NMR (C_6D_6 , δ) 0.12 (s, 6 H), 1.16 (s, 36 H), 2.08 (s, 6 H), 2.71 (s, 12 H), 6.74 (s, 4 H); ^{13}C NMR (C_6D_6 , δ) -3.7, 21.0, 21.9, 26.1, 30.3, 128.8, 137.5, 142.4, 145.2; ^{29}Si NMR (C_6D_6 , δ) 22.4, 25.1; HRMS m/z calcd for $C_{36}H_{64}GeSi_3$ 654.3536, found 654.3535; UV-vis (hexane) $\lambda_{max/nm}$ (ϵ) 285 (7400), 424 (3200).

These unsymmetrical disilenes are quite stable even in solution, and over a couple of months at room temperature no isomerization has been observed. This is in contrast to the behavior of both unsymmetrical tetraaryl- and tetrasilyl-substituted disilenes of the $A_2Si=SiB_2$ type, which isomerize at room temperature to give an equilibrium mixture of the *E*- and *Z*-isomers of the $ABSi=SiAB$ type.^{3c,k,4} The germasilene **4** is also quite stable in solution, in contrast to the facile germasilene-to-silylgermylene rearrangement by a 1,2-mesityl shift of tetramesitylgermasilene.^{9b}

In the ^{29}Si NMR spectrum of **2b**, measured by an inverse-gate pulse sequence, three signals are observed at +8.2, +24.1, and +148.6 ppm with relative intensities of 1:2:1. On the basis of 2D Si-H NMR spectroscopy, the largest signal at +24.1 ppm is assigned to the tBu_2MeSi groups; the other two signals having equal intensity at +8.2 and +148.6 ppm are assigned to the silyl- and aryl-substituted sp^2 silicon atoms, respectively. The other disilenes also show similar ^{29}Si NMR chemical shifts of the sp^2 silicon atoms: +152.3 (**2a**), +137.2 (**3a**), +142.0 ppm (**3b**) for the aryl-substituted sp^2 silicon atoms; -0.8 (**2a**), +14.0 (**3a**), +14.9 ppm (**3b**) for the silyl-substituted sp^2 silicon atoms. The germasilene also exhibits a ^{29}Si NMR resonance of the tBu_2MeSi -substituted sp^2 silicon atom at +22.4 ppm, which supports the validity of the above assignments. The tetraaryldisilenes and tetrakis(trialkylsilyl)disilenes are reported to give signals of the sp^2 silicon atoms around 53–66^{1,3d,4} and 131–156 ppm^{3j,k}, respectively. The resonances of sp^2 silicon atoms substituted by the aryl groups in **2** and **3** are largely downfield shifted relative to that of tetraaryldisilene; in contrast, the chemical shifts of sp^2 silicon atoms substituted by iPr_3Si or tBu_2MeSi groups are largely upfield shifted relative to that of tetrakis(trialkylsilyl)disilene. The reason for such unusual large upfield and downfield shifts of the sp^2 silicon atoms is not clear, but similar trends are reproduced by a GIAO-B3LYP calculation of the model compound $(Me_3Si)_2Si=SiMes_2$; the chemical shift of the Me_3Si -substituted silicon atom (47.8 ppm) is far more upfield shifted than that of the mesityl-substituted one (156.1 ppm).¹⁴

The disilenes and germasilene undergo regioselective additions of methanol.¹⁵ Disilene **2b** readily reacted with methanol in THF to give the corresponding adduct **5** as

(13) For the spectral data of **2a**, **3a**, and **3b**, see the Supporting Information.

(14) The GIAO-B3LYP calculation was carried out using the Gaussian 98 program with basis sets 6-311G(3d) for Si and 6-311(d) for C and H. Geometry optimization was performed at the B3LYP/6-31G(d) level.

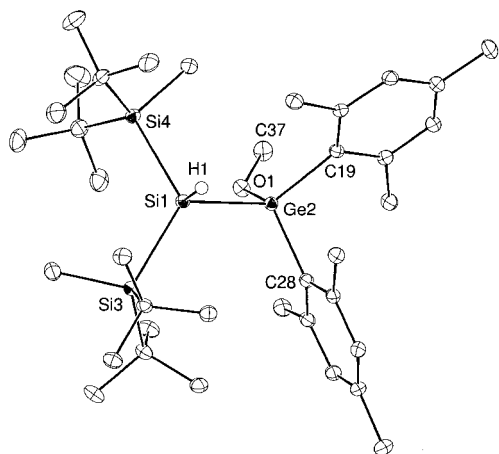


Figure 1. Molecular structure of **6** with thermal ellipsoids drawn at the 30% level (hydrogen atoms are omitted for the clarity). Selected bond distances [Å]: Si1–Ge2 2.4614(8), Si1–Si3 2.423(1), Si1–Si4 2.431(1), Ge2–O1 1.804(2), Ge2–C19 2.003(3), Ge2–C28 1.986(3). Selected bond angles [deg]: Ge2–Si1–Si3 106.1(0), Ge2–Si1–Si4 120.7(0), Si3–Si1–Si4 120.9(0), Si1–Ge2–O1 97.6(1), Si1–Ge2–C19 124.6(1), Si1–Ge2–C28 112.0(1), O1–Ge2–C19 107.8(1), O1–Ge2–C28 110.9(1), C19–Ge2–C28 103.7(1).

a single product in quantitative yield, the structure of which was determined by spectroscopic and X-ray crystallographic methods.¹⁶ The methoxy group is regioselectively bonded to the silicon atom substituted by the two mesityl groups. In the unsymmetrical disilenes, the sp^2 silicon atom connected to the two mesityl groups is more positive than the other sp^2 silicon atom, due to

the difference in electronegativity of Si and C. Actually, the calculated natural atomic charges on sp^2 silicon atoms in the model $(Me_3Si)_2Si=SiMes_2$ are -0.355 for $(Me_3Si)_2Si$ and $+0.958$ for Mes_2Si at the B3LYP/6-31(d) level. Thus, the methoxy group is attached to the more positive silicon atom with mesityl substituents.

The germsilene **4** also reacted with methanol to give a single product, **6**,¹⁷ in which the methoxy group is unexpectedly bonded to the germanium atom, as shown in Figure 1. This result shows regioselectivity opposite that of tetramesitylgermsilene, which gives [dimesityl(methoxy)silyl]dimesitylgermane, in which the methoxy group is attached to the silicon atom.^{9a,b} The regioselectivity in **4** can be well understood in terms of the polarized $Si^{\delta-}=Ge^{\delta+}$ double bond, caused by the difference in electronegativity of the substituents, as found in the methanol addition to the disilenes **2** and **3**. The calculated atomic charges (-0.332 for $(Me_3Si)_2Si$ and $+0.834$ for Mes_2Ge) in the model $(Me_3Si)_2Si=GeMes_2$ at the B3LYP/6-31G(d) level also support the experimental result.

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Supporting Information Available: Tables giving the details of the X-ray structure determination, thermal ellipsoid plots, fractional atomic coordinates, anisotropic thermal parameters, bond lengths, and bond angles for **5** and **6**, ¹H NMR, ¹³C NMR, and ²⁹Si NMR charts of **2b**, and spectral data of **2a**, **3a**, and **3b**. This material is available free of charge via the Internet at <http://pubs.acs.org>.

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(15) For the mechanistic investigation of the addition of alcohols to disilenes, see: Sakurai, H. *The Chemistry of Organic Silicon Compounds*; Rappoport, Z., Apeloig, Y., Eds.; John Wiley & Sons Ltd.: New York, 1998; Vol. 2, Chapter 15, and references cited therein.

(16) Spectroscopic data for **5**: Mp 203–204 °C; ¹H NMR (C_6D_6 , δ) 0.35 (s, 6 H), 1.12 (s, 18 H), 1.17 (s, 18 H), 2.09 (s, 6 H), 2.47 (s, 12 H), 3.35 (s, 3 H), 3.78 (s, 1 H), 6.70 (s, 4 H); ¹³C NMR (C_6D_6 , δ) -1.7 , 21.8, 25.5, 30.3, 30.4, 51.8, 129.8, 135.5, 138.8, 143.9; ²⁹Si NMR (C_6D_6 , δ) -107.1 , 5.4, 19.1. Anal. Calcd for $C_{37}H_{68}OSi_4$: C, 69.30; H, 10.69. Found: C, 69.61; H, 10.37. Crystal data of **5**: $C_{37}H_{68}OSi_4$, fw = 641.27, triclinic, space group $P\bar{1}$, $a = 10.9930(8)$ Å, $b = 11.2640(5)$ Å, $c = 18.314(1)$ Å, $\alpha = 103.009(4)^\circ$, $\beta = 97.239(3)^\circ$, $\gamma = 113.272(4)^\circ$, $V = 1970.4(2)$ Å³, $Z = 2$, $d_{calc} = 1.081$ g·cm⁻³, temperature 120 K, $R = 0.0557$ ($I > 2\sigma(I)$), $R_w = 0.1634$ (all data), GOF = 1.026.

(17) Spectroscopic data for **6**: Mp 177–178 °C; ¹H NMR (C_6D_6 , δ) 0.38 (s, 6 H), 1.11 (s, 18 H), 1.17 (s, 18 H), 2.08 (s, 6 H), 2.52 (s, 12 H), 3.53 (s, 3 H), 4.08 (s, 1 H), 6.70 (s, 4 H); ¹³C NMR (C_6D_6 , δ) -1.9 , 21.7, 23.0, 30.22, 30.24, 53.2, 129.7, 138.4, 139.3, 143.3; ²⁹Si NMR (C_6D_6 , δ) -92.9 , 19.7. Anal. Calcd for $C_{37}H_{68}GeOSi_3$: C, 64.80; H, 9.99. Found: C, 64.94; H, 9.94. Crystal data of **6**·(toluene)_{0.5}: $C_{37}H_{68}OSi_4$ ·(C₇H₈)_{0.5}, fw = 731.89, triclinic, space group $P\bar{1}$, $a = 11.0570(7)$ Å, $b = 11.2600(9)$ Å, $c = 18.539(1)$ Å, $\alpha = 81.261(4)^\circ$, $\beta = 85.511(4)^\circ$, $\gamma = 67.188(4)^\circ$, $V = 2102.4(3)$ Å³, $Z = 2$, $d_{calc} = 1.083$ g·cm⁻³, temperature 120 K, $R = 0.0520$ ($I > 2\sigma(I)$), $R_w = 0.1389$ (all data), GOF = 0.944.